

L Number	Hits	Search Text	DB	Time stamp
1	1430	((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
2	100	(((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
3	96	((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:10
4	8	((((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
5	461	(((((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon)) not (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
6	337	(((((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:12
7	335	(heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:15
8	4	((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and ((nozzle or inject\$3 or inlet)) ) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:18

10	53	((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3 ) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3 ) and puls\$3 ) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3 ) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule) ) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon)) not (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)) ) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) ) ((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet)) ) (((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and ((nozzle or inject\$3 or inlet)) ) and (silicon near granule) )) and @pd>=20040107	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:20
-	2838	((422/129,139,145,146,147) or (118/716)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:46
-	1409	(((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
-	94	((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
-	2	("20020081250").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/06 18:18
-	3254	(422/198,194,190,110).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:00
-	92	((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:10
-	87	(((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:01

-	2838	((422/129,139,145,146,147) or (118/716)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:46
-	8	(((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
-	439	(((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon)) not (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
-	94	(((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 10:59
-	324	(((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) )	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:12
-	319	(heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:13
-	311	((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet)) ) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) ) )	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:15
-	4	((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet)) ) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:24

	369	<p>((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (nozzle or inject\$3 or inlet)) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ))))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:15
	58	<p>((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (nozzle or inject\$3 or inlet)) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 )))) not ((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet)) ) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ( (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3 ))))</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:16
	4	<p>((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and ((nozzle or inject\$3 or inlet)) ) and (silicon near granule)</p>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:18